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PATENT
ATTORNEY DOCKET NO.: 049128-5144

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)	
)	
Byung Chul AHN, et al.)	Confirmation No.: 8591
)	
Application No.: 10/774,701)	Group Art Unit: 2871
)	
Filed: February 10, 2004)	Examiner: Vip Patel
)	
For: METHOD OF PATTERNING)	
TRANSPARENT CONDUCTIVE FILM,)	
THIN FILM TRANSISTOR SUBSTRATE)	
USING THE SAME AND FABRICATING)	
METHOD THEREOF)	

The Commissioner of Patents
U.S. Patent and Trademark Office
Alexandria, VA 22314

Sir:

RESPONSE TO RESTRICTION REQUIREMENT

In the Office Action dated November 23, 2005, the Examiner required restriction under 35 U.S.C. § 121 between Group I (claims 24-30), Group II (claims 1-23 and 49-87) or Group III (claims 31-48). Applicants hereby elect Group II (claims 1-23 and 49-87) with traverse for examination. Applicants respectfully request formal examination of this application.

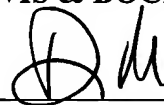
Applicants respectfully assert that no undue burden would be place upon the Examiner to examine each of the alleged Groups of invention. Accordingly, Applicants respectfully request that the Examiner withdraw the Requirement and concurrently examine each of the alleged Groups I, II, and III at this time.

If there are any other fees due in connection with the filing of this response, please charge the fees to our Deposit Account No. 50-0310. If a fee is required for an extension of time under 37 C.F.R. § 136 not accounted for above, such extension is requested and the fee should also be charged to our Deposit Account.

Respectfully submitted,

MORGAN, LEWIS & BOCKIUS LLP

By: _____



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Dated: December 23, 2005

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